

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant(s) : Sung Soo Si et al. Art Unit : 1792  
Serial No. : 10/595,203 Examiner : DHINGRA, RAKESH K.  
Filed : March 23, 2006 Action Date : January 6, 2009  
Title : PLASMA RAPID THERMAL PROCESS APPARATUS IN WHICH  
SUPPLY PART OF RADICAL SOURCE IS IMPROVED

**Mail Stop AF**

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

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**AMENDMENT**

Dear Examiner:

In response to the Final Office Action of January 6, 2009, please amend the above-referenced application as follows.

**Amendment to Claims** begins on page 2 of this paper.

**Remarks** begin on page 5 of this paper submission.

**Request of Continued Examination** attached to the end of this submission.

*The Commissioner is hereby authorized to charge fees, if any,  
or credit any overpayment to **Deposit Account No 50-3566**.*